Docket No.

0039-7632-0X

IN RE APPLICATION OF:

Hiro

GROUP Corres. and Mail

SE UNDER 37 CFR 1.116-EXPEDITED PROCEDURE EXAMINING

SERIAL NO:

09/531,163

March 17, 2000

AQUEOUS DISPERSION, AQUEOUS DISPERION FOR CHEMICAL MECHANICAL POLISHING USED

FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, METHOD FOR MANUFACTURE OF

FOR:

FILED:

SEMICONDUCTOR DEVICES, AND METHOD FOR FORMATION OF EMBEDDED WIRING

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

RECEIVED APR - 9 2002 TC 1700 Transmitted herewith is an Amendment and Request for Reconsideration w/ Marked-Up Copy in t identified application.

No additional fee is required

Small entity status of this application under 37 C.F.R. §1.9 and §1.27 is claimed.

Additional documents filed herewith: Request for Extension of Time (one month)

The Fee has been calculated as shown below:

CLAIMS	CLAIMS REMAINING		HIGHEST NUMBER PREVIOUSLY PAID	NO. EXTRA CLAIMS		RATE		CALCULATIONS
TOTAL	23	MINUS	46	0	×	\$18	=	\$0.00
INDEPENDENT	6	MINUS	12	0	×	\$84	=	\$0.00
	*	☐ MULT	JLTIPLE DEPENDENT CLAIMS			\$280	=	\$0.00
		TOTAL OF ABOVE CALCULATIONS						\$0.00
***		☐ Reduction by 50% for filing by Small Entity					\$0.00	
		☐ Recordation of Assignment			+	\$40	=	\$0.00
						TOTA	ΑL	\$0.00

- A check in the amount of **<u>\$110.00</u>** is attached.
- Please charge any additional Fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.
- M If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time may be charged to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

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